

GREAT TALENT TECHNOLOGY LIMITED

RM602,T3 Software Park,Hi-Tech Park South,Nanshan,Shenzhen,China

Federal Communications Commission

Office of Engineering and Technology Laboratory Division

7435 Oakland Mills Rd.

Columbia MD 21046

Attn: Office of Engineering and Technology

FCC ID: 2ALZM-F30

To whom it may concern:

GREAT TALENT TECHNOLOGY LIMITED hereby declares that the MIF values detailed below are based on worst case operating modes for all air interfaces for which the HAC M-rating is provided based on the current methodology ANSI C63.19 2011withpre-determined MIF values which provided by Speag.

UID	Communication System Name	MIF(dB)
10081	CDMA2000 (1xRTT, RC3)	-19.71
10295	CDMA2000 (1xRTT, RC1 SO3, 1/8th Rate 25 fr.)	3.26
10403	CDMA2000 (1xEV-DO, Rev. 0)	-17.67
10169	LTE-FDD(SC-FDMA,1RB,20MHz, QPSK)	-15.63
10170	LTE-FDD(SC-FDMA,1RB,20MHz, 16-QAM)	-9.76
10171	LTE-FDD(SC-FDMA,1RB,20MHz, 64-QAM)	-9.93

Sincerely,



He chunli / Manager

GREAT TALENT TECHNOLOGY LIMITED

Tel: 0755-86638991

E-mail: hchunli@unimaxcomm.com